

Base developable discharge toplayer for E-beam resists

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 US4025704[Report a data error here](#)**Abstract of EP0540448**

Aqueous base soluble conducting polymers are disclosed, as is their use to dissipate an electrical charge and thereby to improve the precision of processes involving charged particle beams. Electrically conductive functionalized polymers include polyanilines, polyparaphenylvinylenes, polythiophenes, polypyrroles, poly-p-phenylene oxides, polyfurans, polyphenylenes, polyazines, polyselenophenes, polyphenylene sulfides and polyacetylenes. Also disclosed are processes for the synthesis of poly (hydroxylanilines) and polythiophenes and compositions and methods for preparing aqueous base soluble conductive films.

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